



Companies Invited to Exhibit at ICLASS 2009

ANSYS/Fluent	Lechler, Inc.
Artium Technologies	Malvern Instruments, Inc.
BETE Fog Nozzle, Inc.	Metropolitan Computing Corporation
CD-adapco	The Munhall Co.
Clean Air Systems	NAC Image Technology
Coen Co., Inc.	National Research Council Canada – Institute for Chemical Process and Environmental Technology
The Cooke Corporation	
Dantec Dynamics Inc.	Nexum Instrumentation
Delavan Gas Turbine Products	Oxford Lasers Ltd.
Dow Chemical Co.	Particle Measurement Systems
Eastman Kodak Co.	Penn-Century Inc.
En'Urga Inc.	Photron USA, Inc.
Forest Protection Limited	Roper Scientific
Fuel Systems Textron	Spray Analysis and Research Services/ Spraying Systems Co.
GE Aviation	
Hamamatsu Photonic Systems	Sympatec, Inc.
Inhale Therapeutic Systems, Inc.	TSI, Inc.
InnovaSystems, Inc.	UCI Combustion Laboratory
INSITEC, Inc.	Vision Research, Inc
LaVision, Inc.	